Listing of the Claims

- (Currently Amended)
 A system for magnetic resonance imaging, comprising:
- a substantially cylindrical cavity-(2);
- wherein the cavity (2) has an axis of symmetry in the direction of a z-axis;
- wherein a subject (3) can be examined within the cavity;
- wherein the subject (3)-has a conductance which is not isotropic in an xyplane which is perpendicular to the z-axis;
- characterized in that wherein an electrically conductive material (4) is placed within the cavity (2), wherein the material (4) has a conductivity and a thickness which render the total conductance in the xy-plane within the cavity to be isotropic.
- (Currently Amended) A system according to claim 1, characterized in that wherein the system is a magnetic resonance imaging apparatus or a radio frequency (RF) coil for magnetic resonance imaging.
- (Currently Amended) A system according to claim 2, eharacterized in that wherein at least a part of the material (4)-is attached to an inner wall (5)-of the cylindrical cavity (2).
- 4. (Currently Amended) A system according to claim 1, eharacterized in that wherein at least a part of the material (4) is attached to a bottom (6) of a substantially plane surface (7) on which the subject (3) can be positioned.
- (Currently Amended) A system according to claim 4, characterized in that wherein the substantially plane surface (7)-is part of a patient's bed.
- (Currently Amended) A system according to claim 3,4 or 5, eharacterized in that wherein the electrically conductive material (4) is removably attached within the cavity (2).

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- (Currently Amended) A system according to claim 1, eharacterized in that wherein the material (4)-is substantially above and below a substantially plane surface (7)
 on which the subject (3)-can be positioned.
- 8. (Currently Amended) A system according to claim 1, eharacterized in that wherein the material (4)-has a planar resistance between about 5 Ω and about 20 Ω .
- (Currently Amended) A system according to claim 7, eharacterized in that wherein the material above the subject (3)-has a planar resistance between about 5 Ω and about 10 Ω.
- 10. (Currently Amended) A system according to claim 7, eharacterized in that wherein the material below the subject (3) has a planar resistance between about 12 Ω and about 16 Ω .
- 11. (Currently Amended) A system according to claim 1, characterized in that wherein the material (4)-is a sheet (8)-being covered by a conductive layer-(9).
- 12. (Currently Amended) A system according to claim 11, eharacterized in that wherein only predetermined parts of the sheet (8) are covered by a conductive layer-(9).
- 13. (Currently Amended) A system according to claim 1, eharacterized in that wherein it is arranged to operate with magnetic fields at or above 3 tesla.

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